

TECHNICAL DATA SHEET

Model 2NR10T-C

Application	Single wafer reactors or vent/transfer
Gas flow rate	Up to 300-350 slm
Negative pressure	Model 2NR10T-C : up to 5-10 mBar Model
Suction of gas	Model 2NR10T: with pump activated venturi, dedicated fan for Hydrogen dilution Model 2NR10AV: with blower fan activated venturi
Scrubbing of contaminants	Model 2NR10T-c: 3-step
Single exhaust inlet	At inlet the gas is distributed over 2 bell chambers fitted with automatic scraper system, independent actuation, as selfcleaning feature
Dimensions	851x802x2050
Weight with water	480 kg
Service	Indoors or outdoors
Installed power	Model 2NR10T: 1.9 kW / 2.4 kW
Water demand	Up to 150 l/h
Optional	Dosing of a chemical additive with pH regulation Mirrors scrubbers (side by side left and right)